Application Serial No. 09/736,795

IN THE CLAIMS:

structures.

Please add the following new claims:

Sylve Sylves

-- 36. (New) A method of exposing a conductive structure that protrudes from a surface of a semiconductor device through a solder mask positioned on the surface of the semiconductor device, comprising:

reducing a thickness of least portions of the solder mask laterally surrounding the conductive

37. (New) The method of claim 36, wherein said reducing comprises reducing a thickness of substantially all of the solder mask.

- 38. (New) The method of claim 36, wherein said reducing comprises exposing the solder mask to at least one of radiation, a plasma, and a shrinking agent.
- 39. (New) The method of claim 36, wherein said reducing comprises removing a material of the solder mask with selectivity over a material of the conductive structures.
- 40. (New) The method of claim 39, wherein said removing comprises etching the material of the solder mask with selectivity over the material of the conductive structures.